



Nature Inspired Manufacturing

Spinach-based photo-catalyst for selective plating on polyimide-based substrates for micro-patterning circuitry

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Spinach-based photo-catalyst for selective plating on polyimide-based substrates for micro-patterning circuitry

<https://doi.org/10.1016/j.cherd.2019.10.044>

The demand...

1. **Reduce** toxicity of electronic fabrication processes
2. Adopt a **rapid, selective** micropatterning technique

CHEMICAL ENGINEERING RESEARCH AND DESIGN 153 (2020) 839–848



Contents lists available at [ScienceDirect](#)

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Spinach-based photo-catalyst for selective plating on polyimide-based substrates for micro-patterning circuitry



Jose Marques-Hueso^{a,*}, Thomas D.A. Jones^{a,c}, David E. Watson^a, Assel Ryspayeva^a, Mohammadreza N. Esfahani^b, Matthew P. Shuttleworth^b, Russell A. Harris^b, Robert W. Kay^b, Marc P.Y. Desmulliez^a

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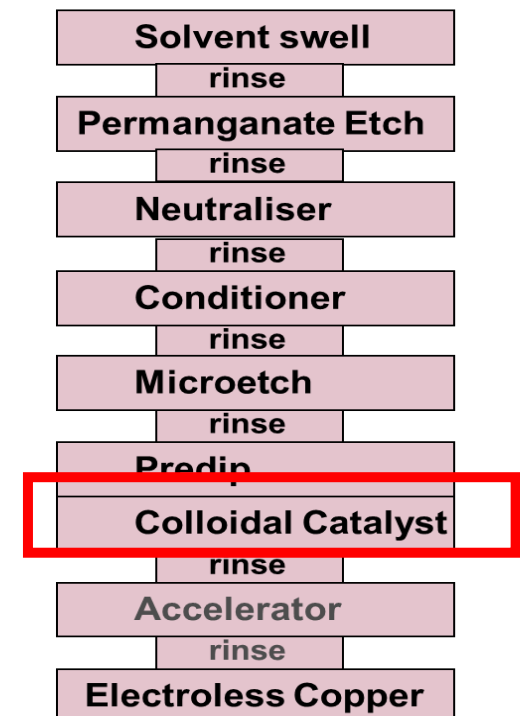
Background

- ❖ The formation of an **economic, rapid catalyst** to receive copper circuitry (electroless)
- ❖ **Ag** is economic (compared to Pd activator used in electroless Cu)

Pd: \$ 77 per gram
Ag: \$ 19 per gram

E'less Cu process

Pd/tin
complex





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Background

- ❖ **Photoreduction** (rather than chemical reduction, formaldehyde) – a selective reduction process
- ❖ Negates the need for high volume solution baths



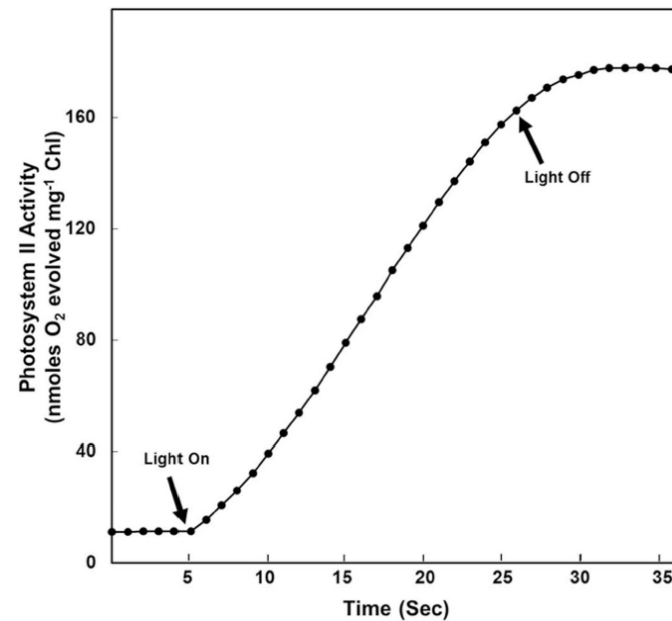
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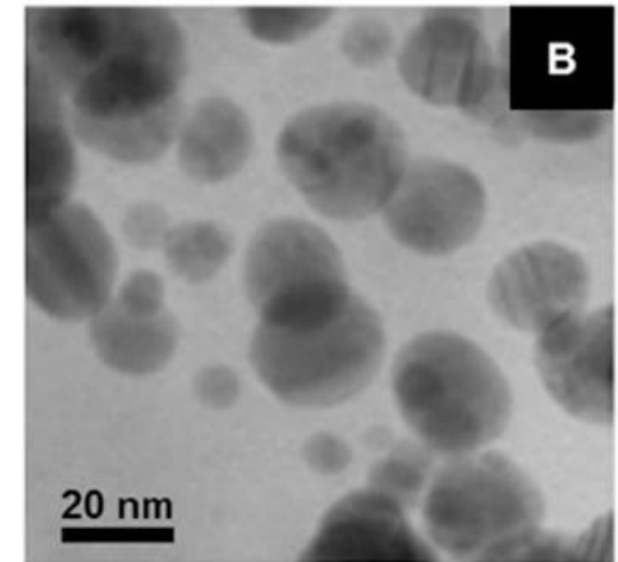
Background

- ❖ Ag photoreduction – to form catalyst for e'less plating
- ❖ Improve Ag photoreduction by the use of an accelerator (photosensitiser)
- ❖ Spinach acts as photosensitiser

Oxygen production (photosensitiser indicator)



Photoreduced Ag Nanoparticles



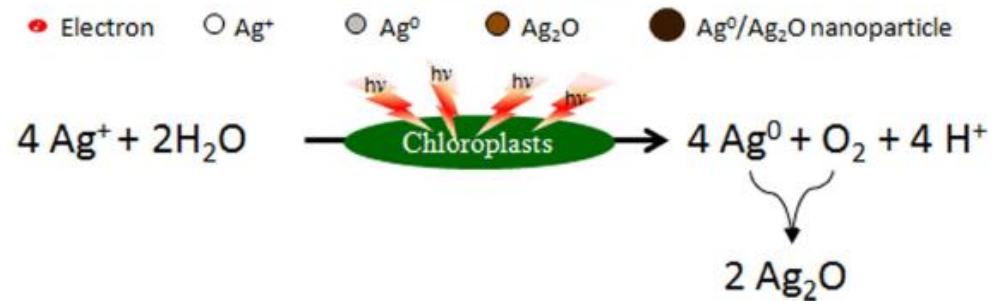
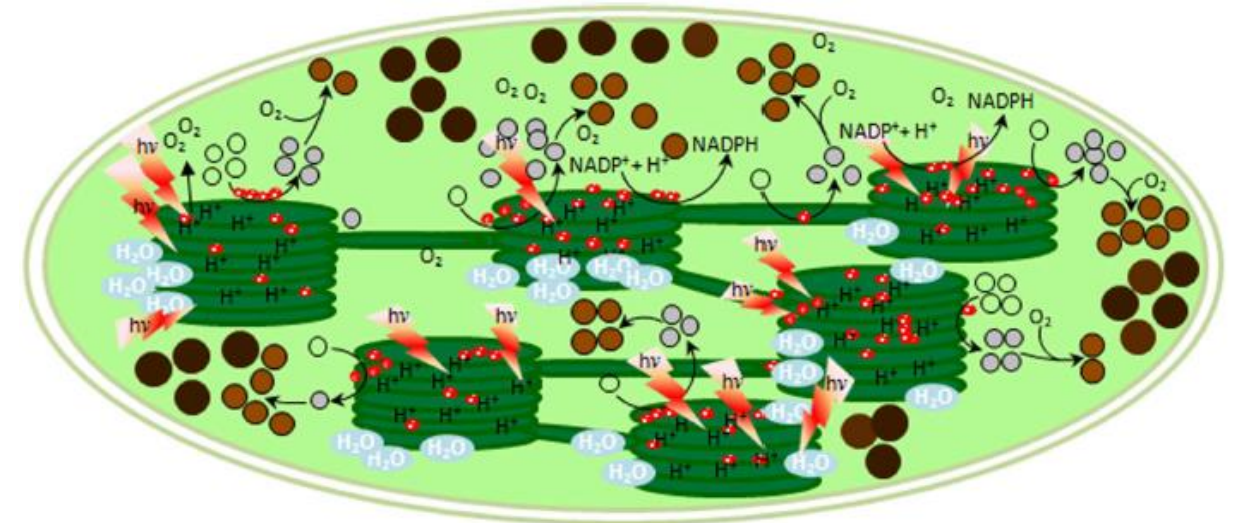
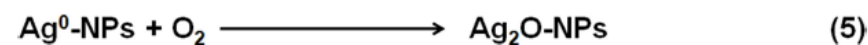
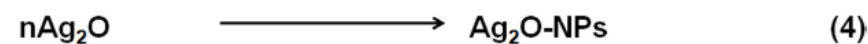
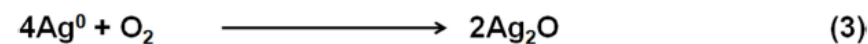
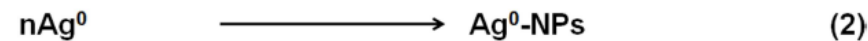
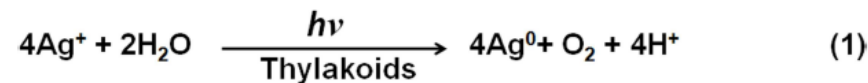
N. Shabnam, P. Sharmila, H. Kim, P. Pardha-Saradhi, Light Mediated Generation of Silver Nanoparticles by Spinach Thylakoids/Chloroplasts, PLoS One. 11 (2016) e0167937. <https://doi.org/10.1371/journal.pone.0167937>.

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Background

❖ Theory: photosensitivity related to chloroplasts within spinach...



N. Shabnam, P. Sharmila, H. Kim, P. Pardha-Saradhi, Light Mediated Generation of Silver Nanoparticles by Spinach Thylakoids/Chloroplasts, PLoS One. 11 (2016) e0167937. <https://doi.org/10.1371/journal.pone.0167937>.

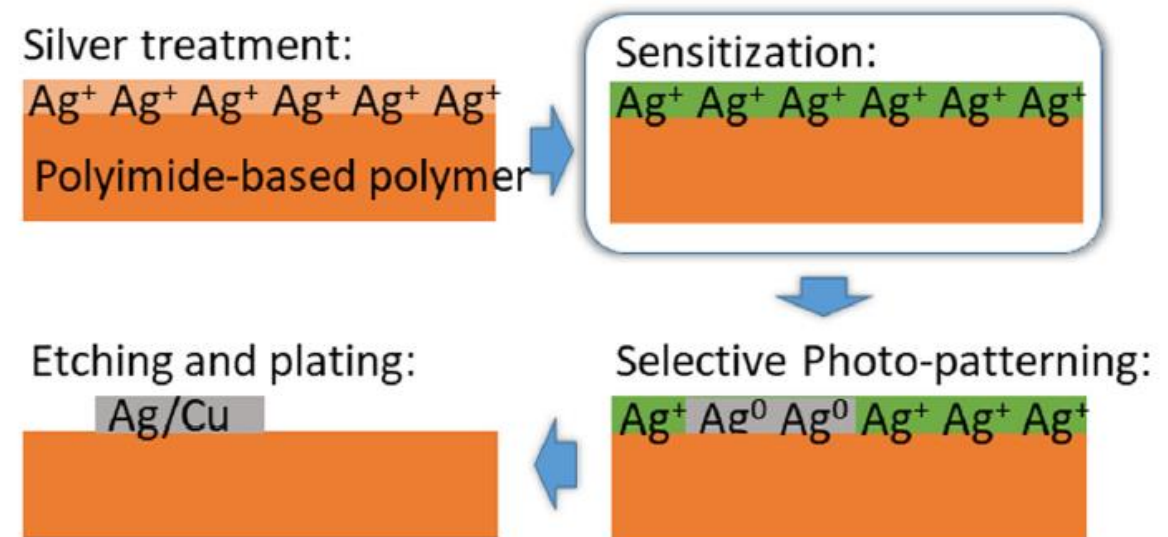


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Our work

- ❖ Processed in polyimide based materials
- ❖ Cheap and used in high value 3-D printers

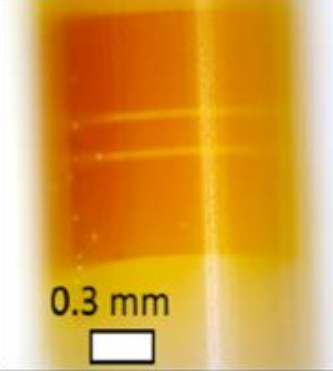

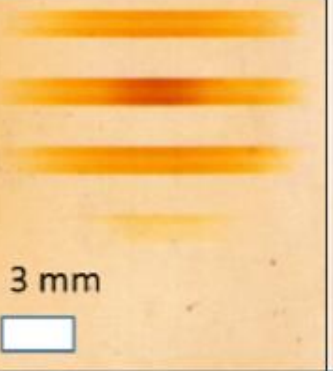
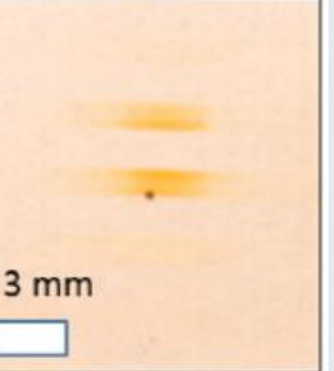
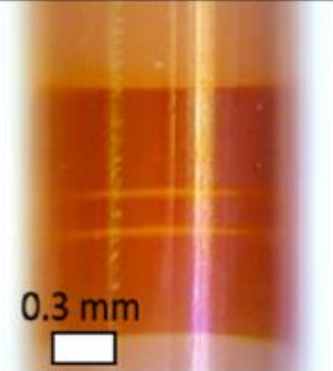
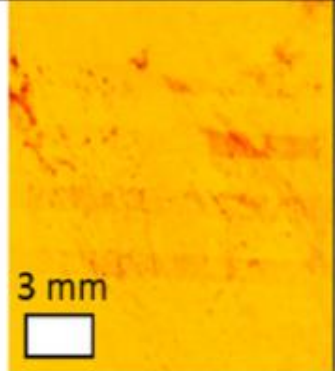
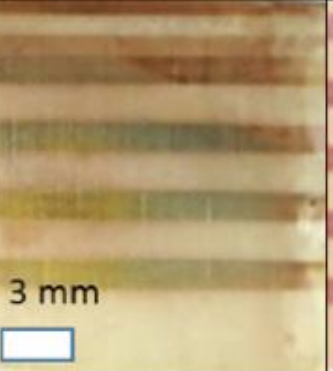
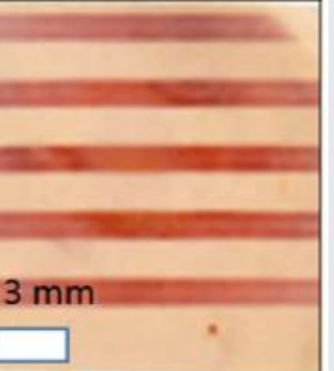


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Our work

Photoreduced Ag nanoparticle / nanofilms

	PEI ULTEM 9085 10 min LED	Polyimide 10 min LED	PEI ULTEM 1000B 10 min LED	PEI ULTEM 1000B 30 sec LED
Without spinach extract	 0.3 mm	 3 mm	 3 mm	 3 mm
With spinach extract	 0.3 mm	 3 mm	 3 mm	 3 mm

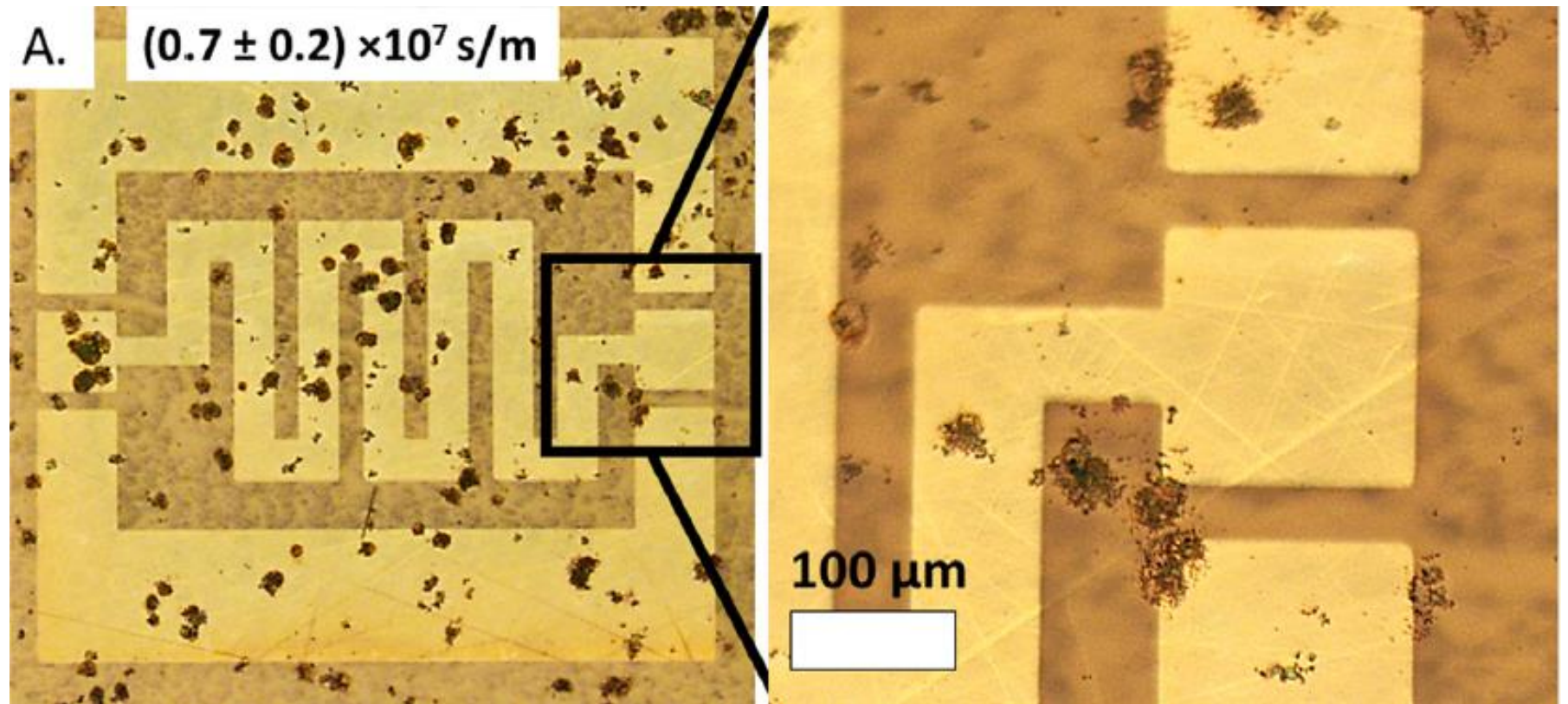
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Our work

Bulk conductivity of Cu: 5.96×10^7 s/m

Electroless Cu onto Ag nanoparticles



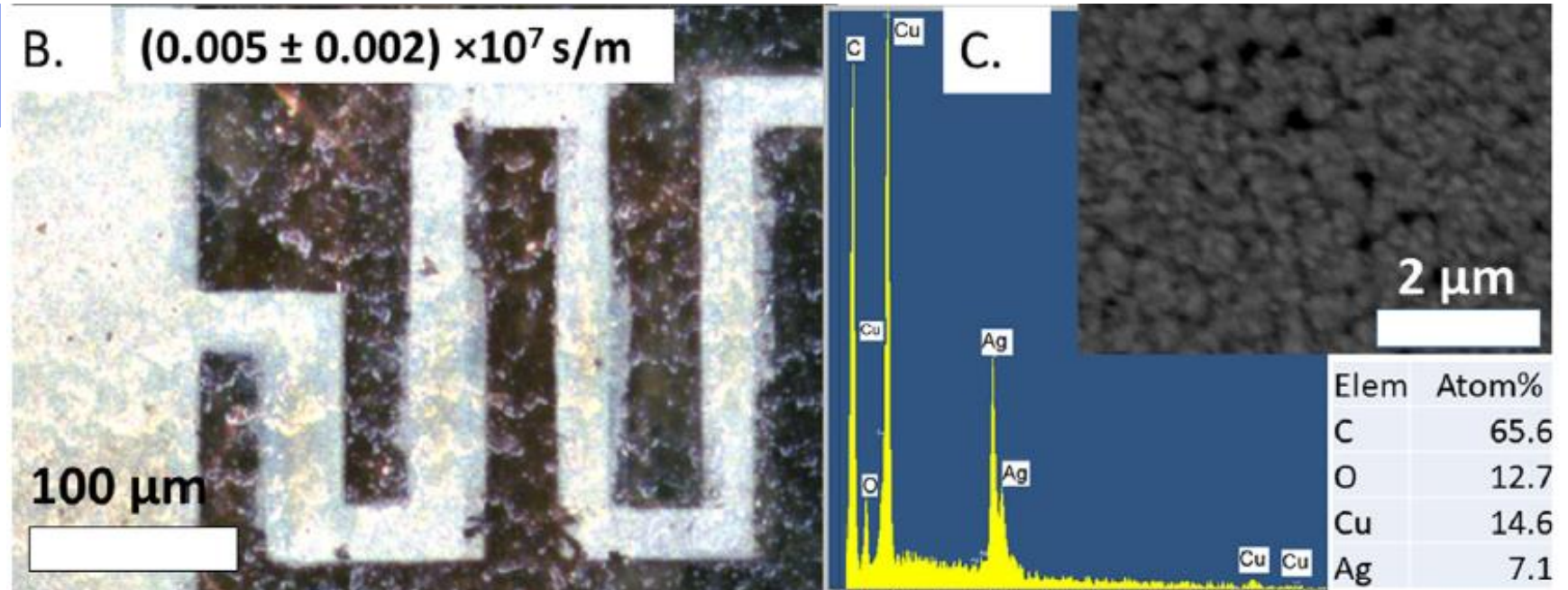
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Ionic liquid Immersion Ag



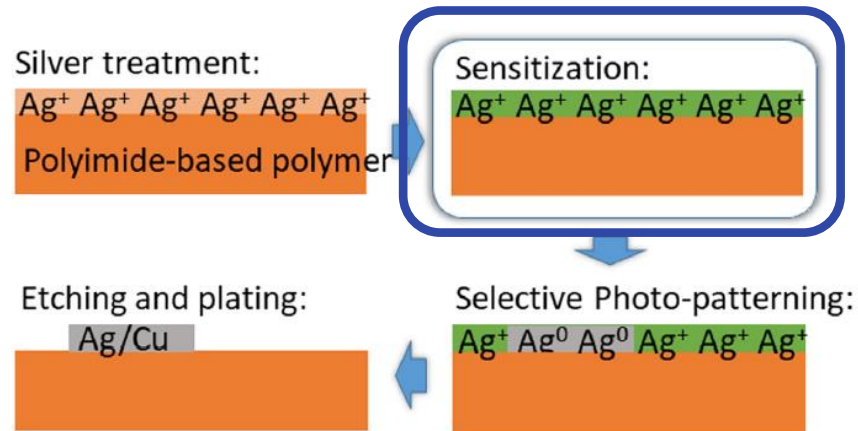


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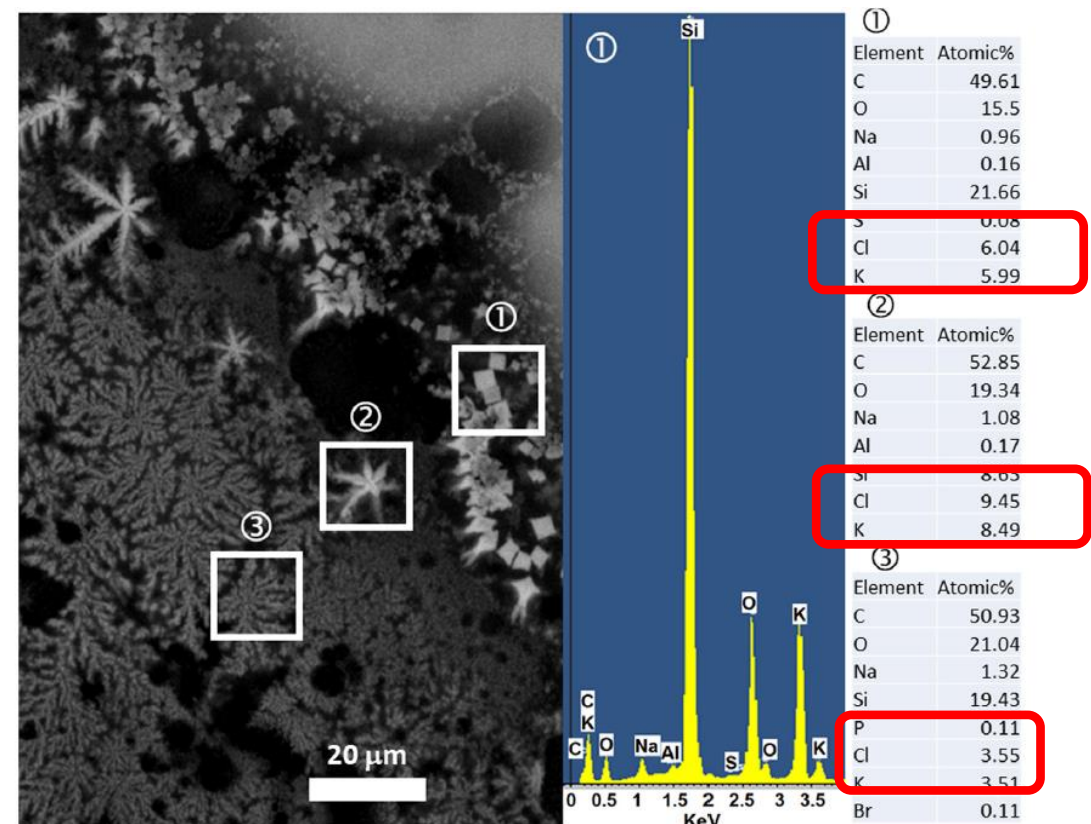
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Our work

❖ A closer inspection of the Ag sensitised process...



Dried spinach extract

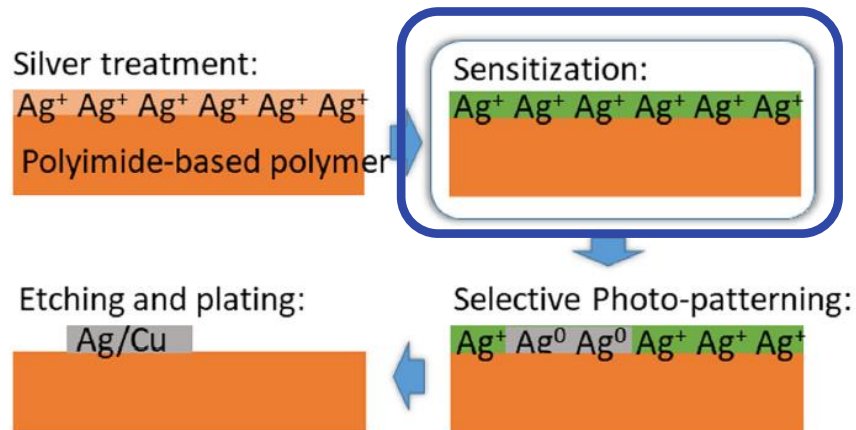


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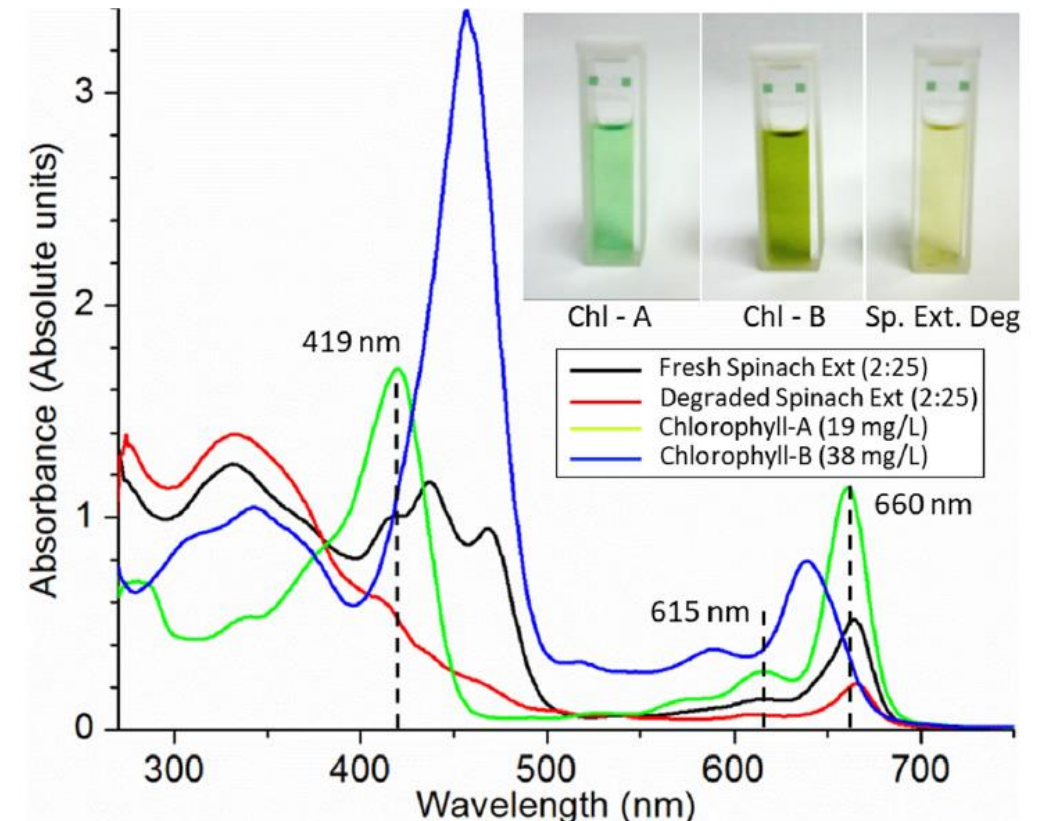
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Our work

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The peaks for chlorophyll don't match

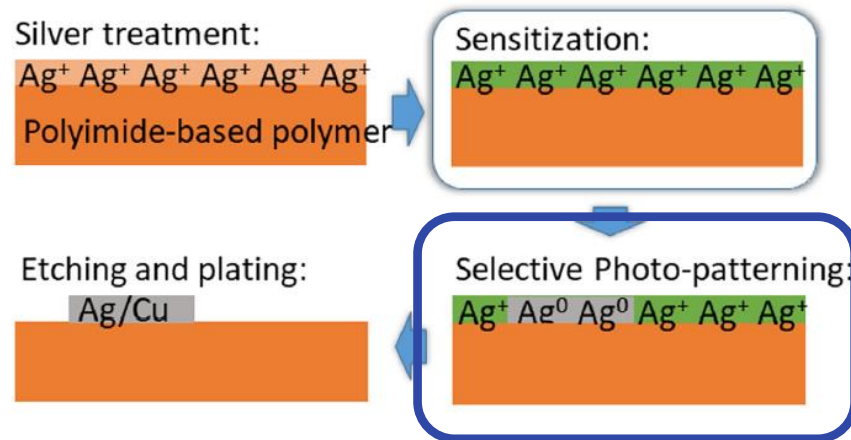


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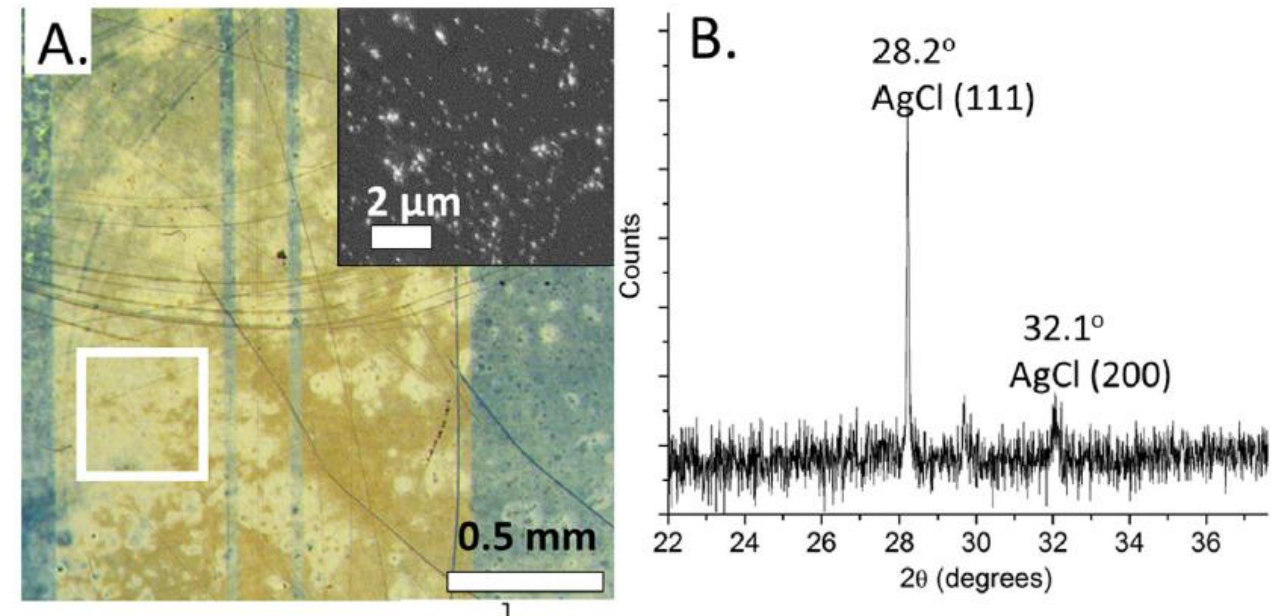
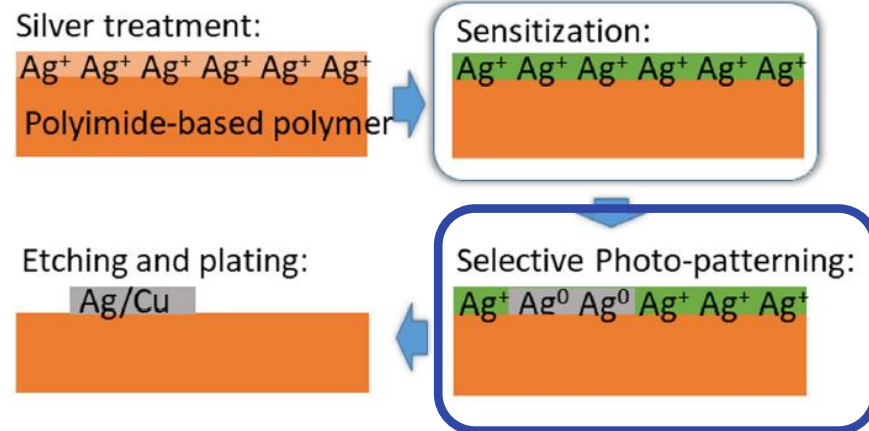
		Fresh Spin. Ext.	Degraded Spin. Ext.	0.01 M KCl
PEI	30 sec	3 sec	3 sec	3 sec
3 mm				
Chl-A	30 sec	10 sec	10 sec	10 sec
3 mm				
Chl-B	30 sec	30 sec	30 sec	30 sec
3 mm				

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Follow up work

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Digital Object Identifier 10.1109/ACCESS.2019.2931324

Selective Metallization of 3D Printable Thermoplastic Polyurethanes

ASSEL RYSPAYEVA¹, THOMAS DAVID ARTHUR JONES², SADEQUE REZA KHAN¹, MOHAMMADREZA NEKOUIE ESFAHANI³, MATTHEW P. SHUTTLEWORTH³, RUSSELL A. HARRIS³, ROBERT W. KAY³, MARC P. Y. DESMULLIEZ¹, (Senior Member, IEEE), AND JOSE MARQUES-HUESO¹

Microelectronic Engineering 209 (2019) 35–40

Contents lists available at ScienceDirect

Microelectronic Engineering

journal homepage: www.elsevier.com/locate/mee

Research paper

A rapid technique for the direct metallization of PDMS substrates for flexible and stretchable electronics applications

Assel Ryspayeva^{a,*}, Thomas D.A. Jones^a, Mohammadreza Nekouie Esfahani^b, Matthew P. Shuttleworth^b, Russell A. Harris^b, Robert W. Kay^b, Marc P.Y. Desmulliez^a, Jose Marques-Hueso^a

FULL PAPER

Flexible Electronics

ADVANCED FUNCTIONAL MATERIALS
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A Rapid Photopatterning Method for Selective Plating of 2D and 3D Microcircuitry on Polyetherimide

Jose Marques-Hueso,* Thomas D. A. Jones, David E. Watson, Assel Ryspayeva, Mohammadreza Nekouie Esfahani, Matthew P. Shuttleworth, Russell A. Harris, Robert W. Kay, and Marc P. Y. Desmulliez

Surface & Coatings Technology 360 (2019) 285–296

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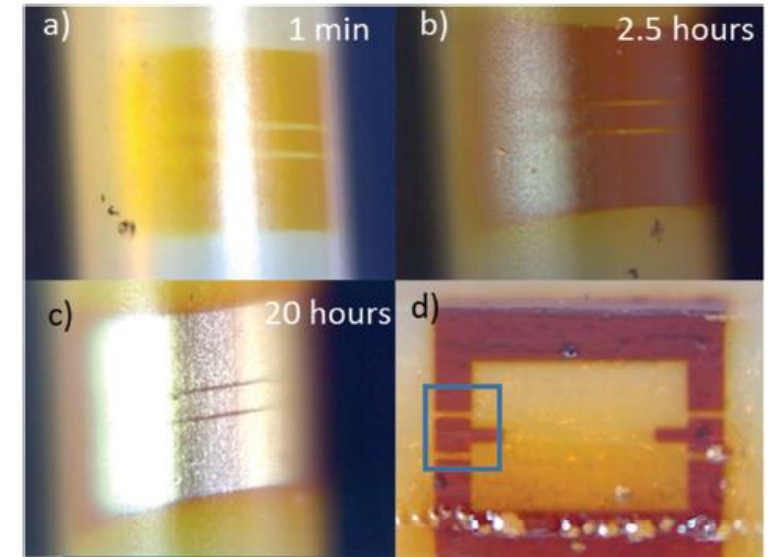
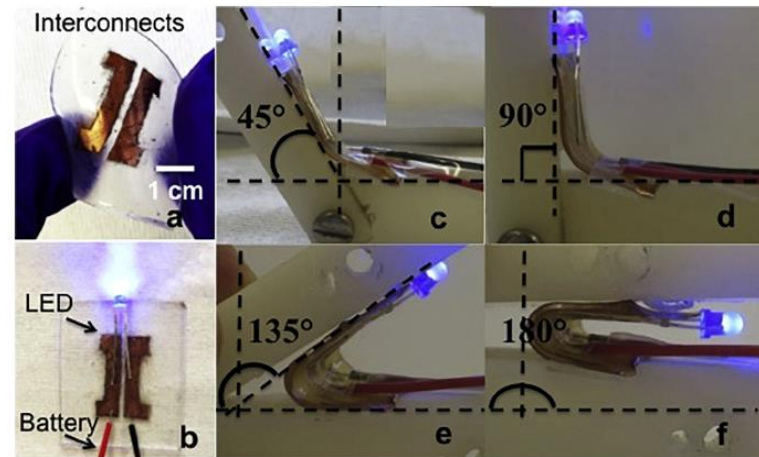
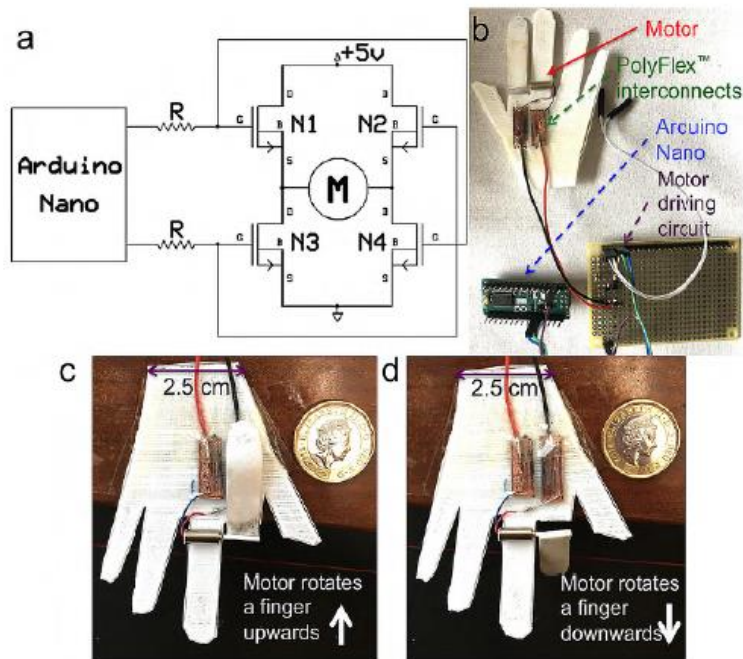
Direct metallisation of polyetherimide substrates by activation with different metals

Thomas D.A. Jones^{a,c,*}, Assel Ryspayeva^a, Mohammadreza N. Esfahani^b, Matthew P. Shuttleworth^b, Russell A. Harris^b, Robert W. Kay^b, Marc P.Y. Desmulliez^a, Jose Marques-Hueso^a

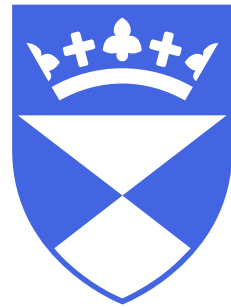
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Follow up work



Thank you for your time



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